Energetics of Mg and B adsorption on polar zinc oxide surfaces from first principles

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We have performed first-principles density-functional projector augmented-wave calculations to investigate the energetics of Mg and B adsorption on polar zinc oxide (ZnO) surfaces, thereby to understand the origin of the peculiar affinities between an epitaxial MgB₂ film and the ZnO substrate. We found that the (0001) Zn surface is relatively inert, while the (0001) O surface is very reactive in the adsorption of atomic species, where a triplaner BO₃ (a hump of MgO₃) binding unit is formed as a consequence of the B (Mg) atom adsorption on the surface. These binding units would be formed at an early stage in the epitaxial growth of MgB₂ film on the ZnO substrate, and subsequently lead to the formation of the reaction products that were recently found in the interface between the MgB₂ film and the ZnO substrate.

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I. INTRODUCTION

The discovery of the superconductivity at a transition temperature \( T_\text{c} \) of 39 K in magnesium diboride \( (\text{MgB}_2) \) has attracted much attention for its scientific implications as well as technological applications. To fabricate MgB₂-based superconductor devices, it is very important to use a high-quality as-grown film prepared at low temperatures. An as-grown process without postannealing is desirable for developing devices such as tunneling junctions and multilayer structures of MgB₂. Several groups have reported low-temperature growth of MgB₂ films on the Al₂O₃ (0001) or Si (111) substrates using molecular beam epitaxy (MBE),⁷–⁹ electron-beam evaporation,⁷ pulsed laser deposition,⁶ and sputtering.⁷ However, these substrates have rather large lattice mismatch with MgB₂.⁸ The as-grown MgB₂ thin films in an ultrahigh vacuum MBE cell have been fabricated under the conditions of low temperature and low growth rate.¹⁰ In these fabrications, several substrates such as MgO, ZnO, Al₂O₃, SrTiO₃, and Si have been explored to further refine the crystallinity of MgB₂ films. Among these substrates, ZnO has been thought to be the best as its lattice constant, \( a = 3.351 \) Å, is very close to that of the MgB₂, \( a = 3.083 \) Å, and both have the same hexagonal lattice symmetry. In fact, c-axis oriented MgB₂ film with \( T_\text{c} = 35.0 \) K on the polar ZnO substrate has been successfully fabricated,¹¹ but, at the same time, a certain amount of unfavorable reaction products has also been found in the interface between the MgB₂ film and the ZnO substrate.¹⁰ This experimental finding suggests the importance of the affinities between substrate and film in addition to minimizing lattice mismatch. Although these reaction products were supposed to be a derivative of the Mg adatom on the ZnO surface, its energetics, as well as the local atomic structure, has not yet been examined. In the present study, we use an \textit{ab initio} method to investigate the energetics of Mg and B adsorption on the ZnO polar surfaces, thereby to understand the origin of the peculiar affinities between the epitaxial MgB₂ film and the ZnO substrate.

II. COMPUTATIONAL DETAILS

A. Structural parameters of the ZnO crystal

Density-functional electronic structure calculations are performed using the Vienna \textit{ab initio} simulation package (VASP).¹² The total energy is calculated using the projector augmented-wave (PAW) method.¹³–¹⁴ We first determine the structural parameters of the ZnO crystal to verify the performance of our computational method. For this purpose, we adopt rather stringent computational conditions; the reciprocal space integration is performed with the 20³ dense Monkhorst-Pack mesh¹⁵ and the high cutoff energy of 500 eV is used in the plane-wave expansion. The exchange-correlation energy functional is treated in the generalized-gradient approximation (GGA) of Perdew et al. (GGA-PBE).¹⁶–¹⁷ For comparisons, we also adopt the local density approximation (LDA) and the GGA of Perdew and Wang (GGA-PW91).²⁰ The lattice parameters optimized in the LDA are slightly underestimated as compared with the experimental values, while those in the GGA (PW91 and PBE) are slightly overestimated (Table I). A similar trend has been found in other calculations, with the lattice constants of the (0001) ZnO surface being reported to be 5.207 Å in the GGA-PW91 and 5.271 Å in the LDA. In all calculations, the lattice constant of the MgB₂ is 3.812 Å, very close to the experimental results. The calculated lattice parameters of the ZnO crystal are summarized in Table I.

<table>
<thead>
<tr>
<th>Method</th>
<th>( a ) (Å)</th>
<th>( c ) (Å)</th>
<th>( u )</th>
</tr>
</thead>
<tbody>
<tr>
<td>LDA</td>
<td>3.202</td>
<td>5.141</td>
<td>0.3817</td>
</tr>
<tr>
<td>PW91</td>
<td>3.288</td>
<td>5.271</td>
<td>0.3817</td>
</tr>
<tr>
<td>PBE</td>
<td>3.295</td>
<td>5.282</td>
<td>0.3817</td>
</tr>
<tr>
<td>Experimental²</td>
<td>3.250</td>
<td>5.207</td>
<td>0.3819</td>
</tr>
</tbody>
</table>

²Reference 24.
are different; one is the \( /H_{20849}\) to slab thickness can be accelerated by filling that the convergence of total energy calculations with respect face; the oxygen \( /H_{20849}\) terminated electron holes \( /H_{20849}\) pseudoatoms with the valency of 0.5 per perpendicular to the materials including diatomic molecules. \( /H_{20849}\) Hereafter, we work. adopt the GGA-PBE to keep consistency throughout this work.

**B. Surface slab**

\( /H_{20849}\) O surface

\( /H_{20849}\) 4 \( /H_{20849}\) polar ZnO surfaces, we used a large hexagonal slab contain- investigating adsorption energetics of an isolated atom on the these two surfaces for the adsorption of Mg and B atoms. To also been reported for ZnO crystal\(^{21,22}\) and for a variety of materials including diatomic molecules. \(^{23}\) Hereafter, we adopt the GGA-PBE to keep consistency throughout this work.

**C. Atomic chemical potentials**

The adsorption energy of an atom \( X \) adsorbed on the site \((=\text{fcc, hcp, or top})\), \( \Delta E_{\text{ads}}^{X_{\text{site}}} \), is defined here as

\[
\Delta E_{\text{ads}}^{X_{\text{site}}} = E_{\text{tot}}^{X_{\text{site}}+X_{\text{site}}} - E_{\text{tot}}^{X_{\text{site}}} = \mu_X,
\]

where \( E_{\text{tot}}^{X_{\text{site}}+X_{\text{site}}} \) and \( E_{\text{tot}}^{X_{\text{site}}} \) are the total energies of the slab with and without an adatom \( X \) on the site, respectively. The atomic chemical potentials \( \mu_X \) of adatoms \( X_{\text{site}} \) are evaluated separately in their reference states. Here, we define the

\[
\begin{array}{cccc}
\text{State} & \text{Symmetry} & \text{Experimental (Å)} & \text{Optimized (Å)} \\
\text{Mg} & \text{Metal hcp} & a=3.209^a & a=3.1918 \\
& & c=5.2107 & c=5.1916 \\
\text{Zn} & \text{Metal hcp} & a=2.664^a & a=2.6570 \\
& & c=4.9494 & c=4.9343 \\
\text{B} & \text{Metal Rhombohedral} & a=5.06^b & a=5.041 \\
& & (\alpha=58^\circ14^c) & (\alpha=58^\circ17^c) \\
\text{O} & \text{O}_2 \text{ molecule}^d & r=1.208^c & r=1.2330 (1.2203^c) \\
\end{array}
\]

\(^a\)Reference 26.  
\(^b\)Reference 27.  
\(^c\) \( \alpha \) is the angle between the crystallographic axes.  
\(^d\) Oxygen molecule in the spin triplet state. The atomic chemical potential is raised by \( \sim 0.51 \) eV if we adopt oxygen molecule in the spin singlet state (\( ^1\text{O}_2 \)).  
\(^e\)Reference 23.

**FIG. 1.** (Color online) (a) Perspective and (b) top views of \((0001)\) Zn surface slab. The large- and middle-sized spheres are the O and Zn atoms, respectively, and the small spheres below the bottom \((0001)\) plane are hydrogenlike peseudoatoms introduced to saturate the dangling bonds. The geometry of the \((00\bar{1}1)\) O surface (not shown here) is obtained by interchanging the atomic species, Zn and O.

**FIG. 2.** (Color online) Atomic configuration of the \((0001)\) Zn surface adsorbing a B atom. Top views are also shown in the squares. Large- and middle-sized spheres are the oxygen and zinc atoms, respectively, and the small dark spheres are the B adsorbed on the surface.
atomic chemical potential as a calculated total energy per atom in its optimized reference state.\(^{28}\) The adsorption energy defined in this way is not the same as the one observed in experiments but may be viewed as a conventional one accounting for the relative stability in the concerned adsorption process. Reciprocal space integrations were performed using the 203 Monkhorst-Pack mesh\(^{15}\) for the bulk metals, and only the \(I\) point is used for an \(O_2\) molecule placed in a large vacuum supercell with volume of 15\(^3\) Å\(^3\). Converged results were obtained using the cutoff energy of 500 eV for the plane-wave expansion. The reference states and their optimized structural parameters are summarized in Table II.

### D. Vacancy formation energies

With the same computational details, we next evaluate the formation energy of a vacancy \(V_X\) (\(X=\text{Zn or O}\) on the surface defined as

\[
\Delta E_f^{V_X} = E_{\text{slab}+V_X}^{\text{tot}} - E_{\text{slab}}^{\text{tot}} + \mu_X,
\]

where \(E_{\text{slab}+V_X}^{\text{tot}}\) is the total energy of the slab with a vacancy on its surface. The equilibrium constraint for the atomic chemical potential\(^{29}\) is given by

\[
\mu_{\text{ZnO(bulk)}} = \mu_{\text{Zn}} + \mu_{\text{O}} + dh_{\text{ZnO(bulk)}},
\]

where \(\mu_{\text{ZnO(bulk)}}\) is the chemical potential of bulk ZnO and customarily obtained as half of the total energy of the ZnO primitive unit cell. With this definition, we obtained enthalpy of formation for the ZnO crystal as \(dh_{\text{ZnO(bulk)}} = -2.903\) eV, which is compared to the experimental value of \(-3.63\) eV.\(^{30}\) By adjusting the atomic chemical potentials in the range \(\mu_X\) to \(\mu_X+dh_{\text{ZnO}}\), we can take into account the Zn-rich and O-rich atmospheric conditions for the defect formations; i.e., in the Zn-rich (O-rich) condition, \(\mu_{\text{Zn}}\) (\(\mu_{\text{O}}\) is fixed at the value evaluated in its reference state, while \(\mu_{\text{O}}\) (\(\mu_{\text{Zn}}\) is replaced by \(\mu_{\text{O}}+dh_{\text{ZnO}}\) (\(\mu_{\text{Zn}}+dh_{\text{ZnO}}\)). This procedure, which is simple and rather tractable, has been successfully used in the first-principles calculations to investigate the defect physics of semiconductors.\(^{29,31}\) Under the oxygen-rich condition, the formation energy of \(V_{\text{Zn}}\) on the (0001) Zn surface is \(-3.42\) eV if we use the oxygen atomic chemical potential with respect to the oxygen molecule in its triplet state \(^3\)O\(_2\) (see Table II). If the oxygen molecule in its singlet state \(^1\)O\(_2\) is adopted as the reference state, that value becomes \(-2.91\) eV, which is compared with the reported theoretical value of \(-3.11\) eV (extrapolated from Fig. 6 of Ref. 22). In the following, we use the \(\mu_{\text{O}}\) obtained in the \(^3\)O\(_2\) state for consistency. For the oxygen vacancy concentration of 25\%, its formation energy per vacancy has been reported to be +1.75 eV for a sixfold (2 × 2) arrangement of the vacancy, \(V_{\text{O}}\)(sixfold), and +1.54 eV for a rectangular arrangement of the vacancy, \(V_{\text{O}}\)(rect).\(^{32}\) However, we obtained the formation energies of +0.67 eV for the \(V_{\text{O}}\)(sixfold) and +0.46 eV for the \(V_{\text{O}}\)(rect), both being about one-third of the previous ones. We cannot trace the origin of these numerical differences in detail but it is possibly ascribed to the difference of the models. In the previous calculations,\(^{32}\) the back side of the slab was not terminated and the extra energy income of the residual dipole would have contributed to the formation energies even after their own energy corrections. For our slab with only one vacancy (this is for the case with lower \(V_{\text{O}}\)

![FIG. 3. (Color online) Atomic configuration of the (0001) Zn surface with an adsorbed Mg atom (middle-sized sphere). Top views are also shown in the squares.](image1)

TABLE III. Adsorption energies \(\Delta E_{\text{ads}}\) (in unit of eV) of the adatom \(X\) (B or Mg) on the (0001) Zn surface. The numbers \((n)\) and species (spc.) of neighboring atoms within 3 Å from the \(X\)=site are tabulated. The慈善ances between the adatom \(X\) on the site and the neighboring atoms are indicated in parentheses (in unit of Å).

<table>
<thead>
<tr>
<th>(X_{\text{site}})</th>
<th>fcc</th>
<th>hcp</th>
<th>top</th>
</tr>
</thead>
<tbody>
<tr>
<td>B (\Delta E_{\text{ads}})</td>
<td>1.977</td>
<td>0.889</td>
<td>4.297</td>
</tr>
<tr>
<td>(n) spc.</td>
<td>3 Zn (2.09)</td>
<td>3 Zn (2.19)</td>
<td>Zn (2.14)</td>
</tr>
<tr>
<td>Mg (\Delta E_{\text{ads}})</td>
<td>0.495</td>
<td>0.474</td>
<td>0.942</td>
</tr>
<tr>
<td>(n) spc.</td>
<td>2 Zn (2.75)</td>
<td>2 Zn (2.71)</td>
<td>Zn (2.76)</td>
</tr>
</tbody>
</table>

TABLE IV. Adsorption energies \(\Delta E_{\text{ads}}\) (in unit of eV) of the adatom \(X\) (B or Mg) on the (0001) O surface. The other details are the same as those in Table III.

<table>
<thead>
<tr>
<th>(X_{\text{site}})</th>
<th>fcc</th>
<th>hcp</th>
<th>top</th>
</tr>
</thead>
<tbody>
<tr>
<td>B (\Delta E_{\text{ads}})</td>
<td>-5.822</td>
<td>-5.642</td>
<td>-0.115</td>
</tr>
<tr>
<td>(n) atm. (Å)</td>
<td>3 O (1.40)</td>
<td>O (1.38)</td>
<td>O (1.27)</td>
</tr>
<tr>
<td>Mg (\Delta E_{\text{ads}})</td>
<td>-4.787</td>
<td>-4.295</td>
<td>-4.789</td>
</tr>
<tr>
<td>(n) atm. (Å)</td>
<td>3 O (1.97)</td>
<td>3 O (2.00)</td>
<td>3 O (1.97)</td>
</tr>
</tbody>
</table>

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concentration of 6.25%), we obtained the formation energy of +0.32 eV.

III. RESULTS AND DISCUSSION

A. Adsorption on the (0001) Zn surface

The results for the energetics of B and Mg adsorption on the (0001) Zn surface are summarized in Table III. Since the adsorption energies are obtained using the conventional atomic chemical potentials evaluated in their standard reference states, we cannot use those values for a quantitative comparison with experiments but may use them to examine the relative affinities of adatoms. The B atom adsorbed on the fcc site attracts three neighboring Zn atoms and lifts them from the surface (Fig. 2). Similarly, the B atom on the top site attracts one Zn atom from the surface. Both of these processes are unlikely to occur because of high energy cost (Table III). On the other hand, the B atom adsorbed on the hcp site forms a bond with the O atom just below the site with a bond length of 1.31 Å, thereby lowering the adsorption energy down to 0.89 eV. This result clearly indicates that the B atom preferably binds to the O atom rather than the Zn atom even on the (0001) Zn surface. All these adsorption processes of a B atom on the Zn surface are endothermic with respect to the reference atomic chemical potential. In contrast, the adsorption energies of the Mg atom on the fcc and hcp sites are almost the same and their local atomic configurations are also nearly identical (Fig. 3). Each Mg atom has three neighboring Zn atoms within the distance of ~2.75 Å (Table III). The adsorption of Mg on the top site needs about twice higher energy than in the other cases, implying that Mg is hardly adsorbed on the top site. Therefore, the Mg atom, as well as B, on the (0001) Zn surface is unlikely to make strong bonds with the surface atoms and would show a rather diffusive behavior avoiding the route climbing over the Zn atom (top site).

B. Adsorption on the (0001) O surface

The results for the adsorption energetics and geometries of the (0001) O surface are summarized in Table IV. We find from these results that, in contrast to the Zn surface, this surface shows an extremely reactive behavior for the adsorption of B and Mg atoms.

The B atom on the fcc site forms triplaner bonds with the three neighbor O atoms in the distances of ~1.4 Å (Fig. 4). The valence charge density map of the (0001) surface clearly shows a covalent bonding feature of the triplaner BO3 binding unit (Fig. 5). Similarly, the B atom on the hcp site forms the same triplaner local atomic configuration by driving out the Zn atom just beneath. Figure 6 schematically shows the triplaner BO3 binding unit found at these adsorption sites. The adsorption energies of these processes are quite low, and thus all energetically favorable. We note here that the triplaner binding unit is an elemental framework in the B2O3.
crystal, where the B-O bond length takes the same value of \( \sim 1.4 \, \text{Å} \). The B atom on the top site binds only to the nearest O atom with the distance of 1.27 Å and the adsorption energy is still negative. Therefore, the adsorption on the top site is exothermic but would be unfavorable because of its relatively high energy cost (\( \sim +5.5 \, \text{eV} \)) compared to the adsorptions on the fcc and hcp sites.

The configurations of Mg atoms adsorbed on the fcc, hcp, and top sites of the O surface show similar local structures. Each of the Mg atoms binds to the three neighbor O atoms at the distance of \( \sim 2 \, \text{Å} \) (Fig. 7). In this case, the O atoms are lifted from the surface and forms a hump of MgO\(_3\) binding unit on the surface. The O-Mg-O bond angle of the binding unit is \( \sim 100^\circ \). We also find that the Mg atom on the hcp site drives the nearest Zn atom out of the original position below the Mg atom. Hence, it is energetically favorable for the Mg atom to be adsorbed on that site even though it induces deformation of the existing Zn-O bond. We can see a similar local atomic structure in the MgO crystal, where each Mg atom has six neighbor O ligands at the distance of \( \sim 2.1 \, \text{Å} \) and a MgO\(_6\) cage is formed, whereas the Mg atom on the (000\(\bar{1}\)) O surface has only three neighbor O atoms at shorter distances of 1.97–2.0 Å and their local geometric structure can be viewed as a fraction of a deformed MgO\(_6\) cage in the MgO crystal.

C. Migration energetics on the (0001) Zn surface

We use the well-established climbing nudged-elastic-band (C-NEB) technique\(^{35,36}\) to explore the energy profiles for the migration process of the adatoms, Mg and B, on the (0001) Zn surface. The calculated energy profile for the Mg migration along the fcc\(\to\)hcp\(\to\)top\(\to\)fcc path is shown in Fig. 8. The energy barrier for the Mg migration from the fcc site to the hcp site is only 0.06 eV. On the other hand, the barrier for the Mg migration along the path climbing over the top site amounts to \( \sim 0.5 \, \text{eV} \). Therefore, the adsorbed Mg atom would migrate along the path with the lowest energy barrier, fcc\(\to\)hcp. We note that it is possible for the Mg to migrate throughout the surface area by taking a zigzag route (fcc\(\to\)hcp\(\to\)fcc\(\to\)\cdots\), i.e., the Mg atom adsorbed on the (0001) Zn surface shows high mobility characteristics. On the other hand, the energy profile for the B migration on the (0001) Zn surface shows a quite different behavior (Fig. 9). The energy barrier for the B migration for the fcc\(\to\)hcp route amounts to \( \sim 1.4 \, \text{eV} \), while it is \( \sim 2.4 \, \text{eV} \) for the reverse route. There is a maximum energy barrier (\( \sim 3.8 \, \text{eV} \)) for the B migration along the hcp\(\to\)top path. The migration of B along the fcc\(\to\)top path also encounters a high energy cost (\( \sim 2.8 \, \text{eV} \)). Therefore, neither of these migration processes would be possible and the B atom adsorbed on the fcc and hcp sites is rather immovable on the (0001) Zn surface and could make bonds with O atoms. We also tried to calculate the energy profile for the Mg and B migrations on the (000\(\bar{1}\)) O surface but could not obtain any converged result. The tendency of divergence in the C-NEB computation of O surface is understandable since the adatoms form strong bonds with surface O atoms. Any of the intermediate migration point between the specific adsorption sites, and hence the migration path on the O surface, would be indefinite.

Kresse et al.\(^{22}\) have reported that there is a unique stabilization mechanism in the (0001) Zn polar surface, where a certain amount of triangular-shaped defects (pits) are formed to effectively maintain its valency, implying that some oxy-
that surface, only the B atom on the hcp site forms a bond relatively inert with respect to the Mg and B adatoms. On the ZnO substrate. We found that the face between the epitaxial MgB2 film and the ZnO substrate. Layer of the reaction products will be left behind in the inter-

These reactions will continue until the excess oxygen

O2 atoms, not only on the (0001) Zn surface but also on the (0001) Zn surface, easily make bonds with both Mg and B atoms. These reactions will continue until the excess oxygen atoms are exhausted on the surface and the binding units will be left behind. We note here that a certain amount of triangular-shaped pits are formed even on the clean Zn surface to reduce its valency. In these pits, some oxygen atoms are bared and again make bonds with both Mg and B atoms. As the result, the surface reactions will continue until the excess oxygen atoms are exhausted on both surfaces, leading to the formation of the reaction products that were recently found in the interface between the MgB2 film and the ZnO substrate. These theoretical results imply that the use of an appropriate buffer layer, which effectively covers the surface oxygen atoms, could suppress the formation of reaction products in the interfaces, or, alternatively, some gettering process for the oxygen at an initial stage of the film formation could work to prevent the formation of reaction products. We need more detailed experimental data for the Mg and B adsorption on the polar ZnO surfaces to verify these implications.

IV. CONCLUSIONS

A first-principles density-functional PAW method was used to investigate the energetics of Mg and B adsorption on the polar ZnO surfaces, thereby to understand the origin of the peculiar affinities between the epitaxial MgB2 film and the ZnO substrate. We found that the (0001) Zn surface is relatively inert with respect to the Mg and B adatoms. On that surface, only the B atom on the hcp site forms a bond with the O atom just below the surface Zn layer and its adsorption energy is as low as 0.89 eV, which clearly indicates that the B atom favors to bind to the O atom rather than to the Zn atom even on the (0001) Zn surface. Therefore, both Mg and B atoms are unlikely to make strong bonds with the surface Zn atoms and would show rather diffusive behavior avoiding the route climbing over the Zn atom (top site). On the other hand, the B atoms adsorbed on both the fcc and hcp sites of the (0001) O surface form the triplanar BO3 binding units, which can also be found in the B2O3 crystal. The Mg atoms adsorbed on the fcc and hcp sites of that surface form a hump of MgO3 binding unit that can be viewed as a fraction of a MgO6 cage found in the MgO crystal. These results suggest that the bare oxygen atoms on the ZnO surface easily make bonds with both the Mg and B atoms. These reactions will continue until the excess oxygen atoms are exhausted on the surface and the binding units will be left behind. We note here that a certain amount of triangular-shaped pits are formed even on the clean Zn surface to reduce its valency. In these pits, some oxygen atoms are bared and again make bonds with both Mg and B atoms. As the result, the surface reactions will continue until the excess oxygen atoms are exhausted on both surfaces, leading to the formation of the reaction products that were recently found in the interface between the MgB2 film and the ZnO substrate. These theoretical results imply that the use of an appropriate buffer layer, which effectively covers the surface oxygen atoms, could suppress the formation of reaction products in the interfaces, or, alternatively, some gettering process for the oxygen at an initial stage of the film formation could work to prevent the formation of reaction products. We need more detailed experimental data for the Mg and B adsorption on the polar ZnO surfaces to verify these implications.

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